

Substitute for form 1449A-PTO  <b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b> <i>(Use as many sheets as necessary)</i>	Complete if known	
	Application Number	10/572,525
	Filing Date	March 20, 2006
	First Named Inventor	Kang, Xuejun
	Group Art Unit	2811
	Examiner Name	Unknown
Sheet 1 of 1		Attorney Docket No: 7989P002

US PATENT DOCUMENTS					
Examiner Initial *	Cite No. <sup>1</sup>	USP Document Number	Publication or Issue Date MM-DD-YYYY	Name of Patentee or Applicant of cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear

FOREIGN PATENT DOCUMENTS					
Examiner Initials*	Cite No. <sup>1</sup>	Foreign Patent Document Country Code/Number/Kind Code (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear  <sup>2</sup>

OTHER DOCUMENTS -- NON PATENT LITERATURE DOCUMENTS					
Examiner Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.			r <sup>2</sup>
		CHU, CHEN F., et al., "Comparison of p-Side Down and p-Side Up GaN Light-Emitting Diodes Fabricated by Laser Lift-Off", <u>Japan Journal of Applied Physics</u> , Vol. 42, (02/15/2003), 147-150			
		LI, W H., et al., "Electrochemical deposition of Copper on patterned Cu/Ta(N)SiO2 surfaces for super filling of sub-micron features", <u>Journal of Applied Electrochemistry</u> , Vol. 31, (2001), 1395-1397			

EXAMINER

DATE CONSIDERED

Based on PTO/BP/28A(28-09) - Substitute Disclosure Statement Form (PTO 1449) as modified by ERI/2 US/28/07

\* EXAMINER: Indicate reference translated, whether or not citation is in conformance with MPEP 608. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. \* Applicant's unique citation designation number (optional). \* Applicant is to place a check mark here if English language translation is attached.